2020 Technology Briefing

Scott DeBoer, EVP November 30, 2020

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Scott DeBoer

Executive Vice President Technology and Products



The New Micron's Journey

Closing the Gap

2016-2020

- Faster node transitions
- Investments towards vertical integration and scale
- Build quality leadership
- Grow high value solutions mix
- Supply growth in line with demand

Technology & Product Leadership

2021+

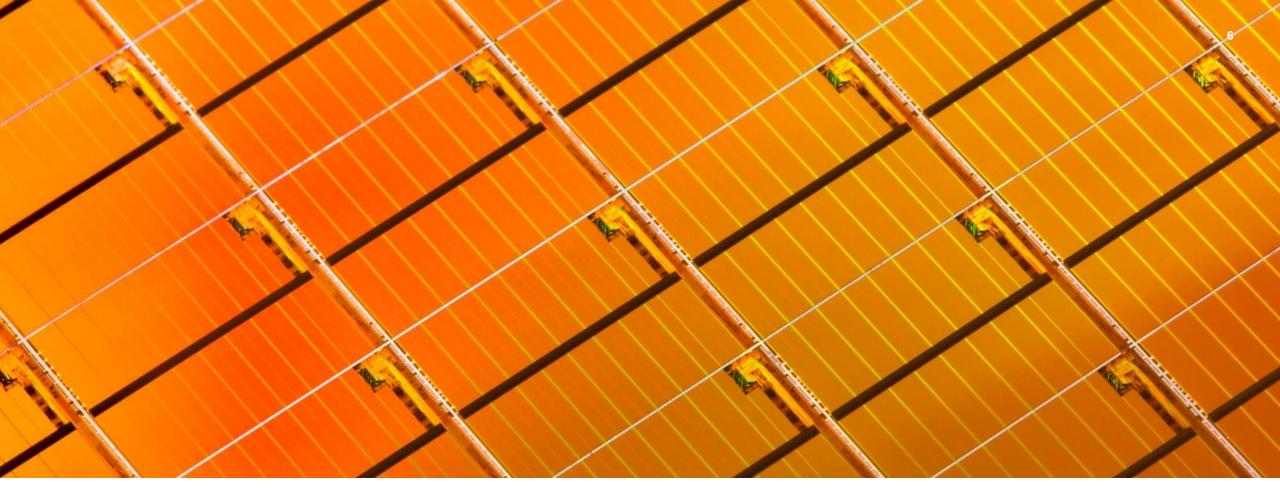
- Introduce leading tech nodes at a typical industry cadence, while maintaining our improved competitive position
- Differentiated solutions ready for heterogenous computing architectures
- Supply growth in line with demand



Agenda

Strategy
Technology
Product





Strategy





R&D Efficiency

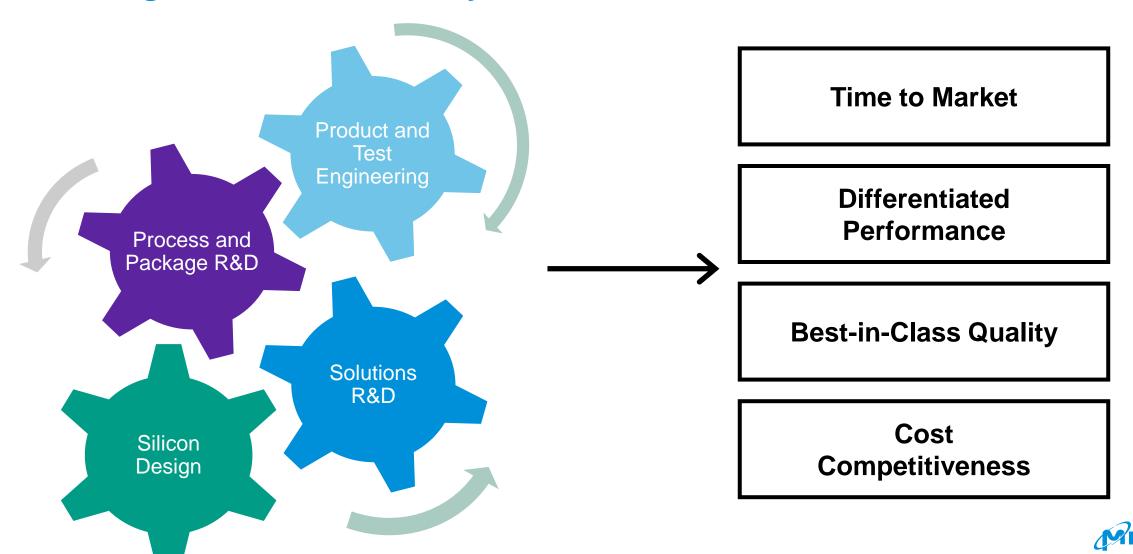
Broadest Portfolio

Team & Culture



Integration of Technology & Product

Enables greater R&D efficiency and customer value creation



Industry's Broadest Portfolio

Ability to leverage core technology across the memory and storage hierarchy

DRAM

Ultra-Bandwidth: HBM2E, GDDR6X

Compute: DDR5

Mobile: Low power leadership

3DXP

Memory: Future development

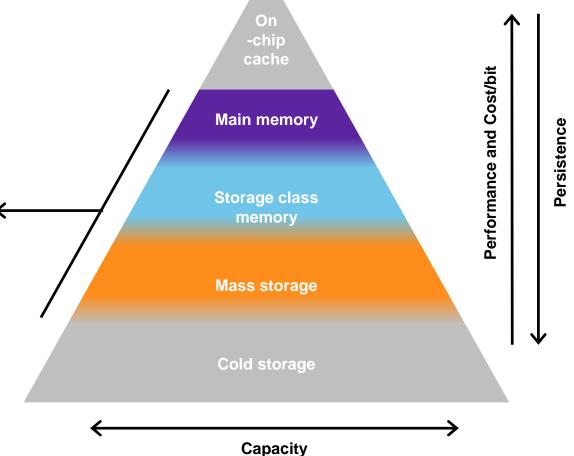
Storage: X100 – world's fastest SSD

NAND

Managed NAND: UFS3.1/2.x, uMCP5

SSD: Client, Datacenter NVMe/SATA

QLC: HDD replacement trajectory





Team & Culture

Uniquely positioned to attract the industry's best global talent



Team

- Global talent fuels innovation
- >50% of R&D new hires with MS, PhD
- >60% technical with industry experience
- Strong talent pipeline, engaged with top global universities

Culture

- Team Member Health & Safety
- Excellence in Execution
- Certified 2020 Great Place to Work
- Forbes 2020 "The Best Employer for Diversity"
- Focus on Environmental Sustainability
 Learn more: August 24, 2020 Sustainability Update

Innovation

- Over 44,000 patents granted and growing*
- Top 25 on US Patent list
- Micron Women Innovate program



^{*}Micron data as of September 3, 2020.



Technology



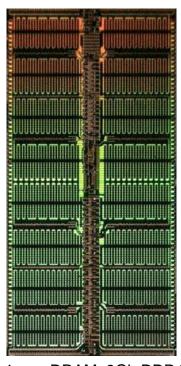


TechnologyDRAM



1α nm: Industry's Most Advanced DRAM

Volume production in 1H-CY21



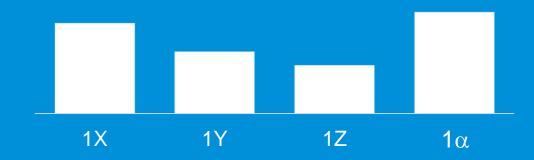
1αnm DRAM: 8Gb DDR4

- ✓ Lowest power mobile DRAM with 15% improvement vs. prior gen
- ✓ Roadmap for highest speed DRAM available across comprehensive portfolio

Achieved with Leading Design Efficiency and Process Technology

- ✓ Industry's most advanced lithography
- √ 40% improvement in density vs. 1Z
 with ~10% driven by design efficiency

DDR4 % Gb/Wafer Increase from Prior Node





DRAM Technology Leadership

Continuing to extend roadmap for cost and performance improvement



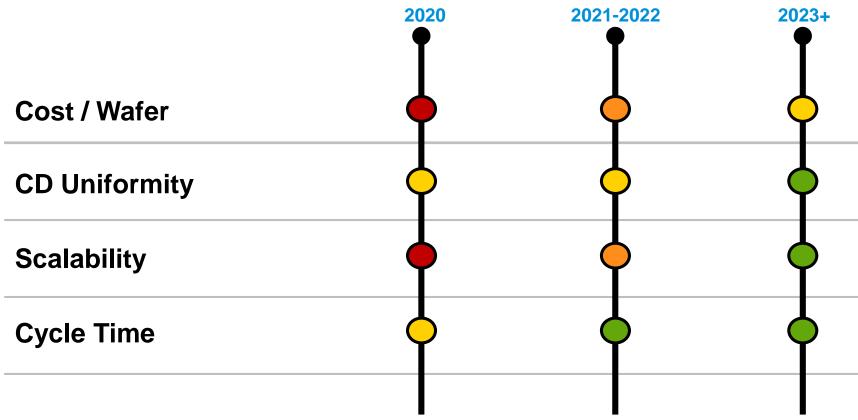
- Path for continued scaling over the next decade
- High performance/low power transistor roadmap enabled by High-κ CMOS
- Continued evaluation of EUV for cost optimized insertion



DRAM EUV Performance Improving

Potential future option for Micron DRAM lithography

DRAM EUV Capability*



^{*}Micron Performance analysis relative to Micron DRAM requirements





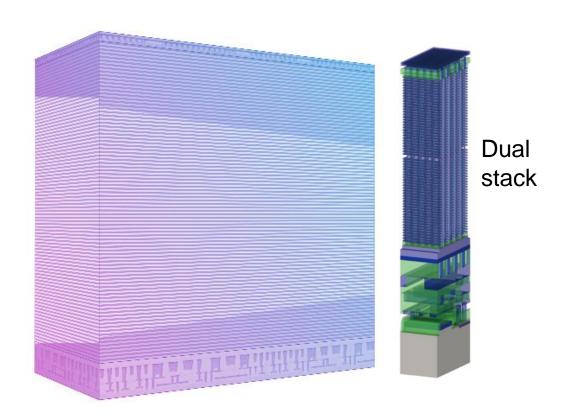
TechnologyNAND



The World's First 176-Layer NAND

Innovation driving breakthrough speed, power efficiency and density

- √ 30% smaller die size than best-in-class competitive offerings
- √ ~1.5x cost reduction vs. 64L/96L transition*
- √ >2x improved power efficiency[†]
- √ >2x better write times[†]
- √ 33% higher data transfer rate[†]



*Cash cost per Gb vs. 64L/96L transition

†versus Micron's high volume, floating-gate 96-Layer 3D NAND

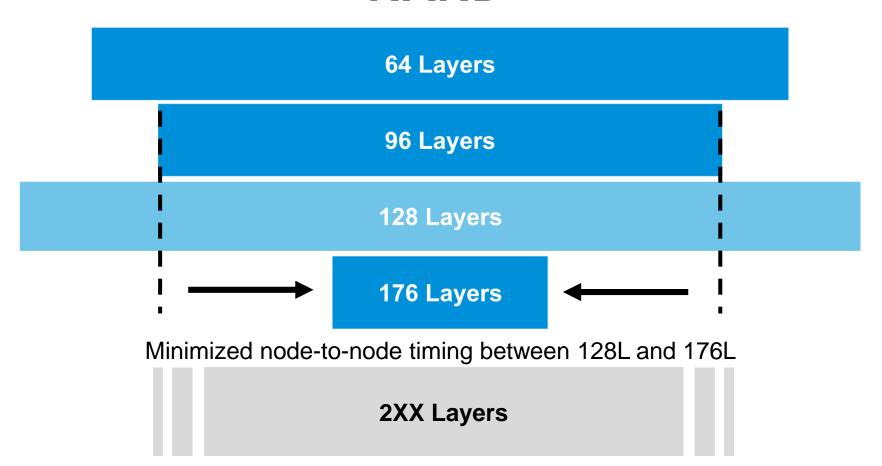
Learn more here on micron.com



Accelerating Time to Market for 176 Layer

Successful replacement gate (RG) transition enables industry leadership

NAND





NAND Technology Leadership

Continuing to extend roadmap for cost and performance improvement



- Continued 3D NAND scaling and cost reductions for several generations
- Combination of replacement gate (RG), charge trap and CMOS under Array delivers performance leadership
- Extend QLC performance leadership



Replacement Gate

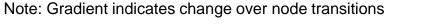
Driving scalability and performance for 3D NAND generations to come

Attribute	<100 Layers	
	Floating Gate	Replacement Gate
Cost Scalability		
Power		
Performance		
Retention		
Endurance		
QLC Compatibility		

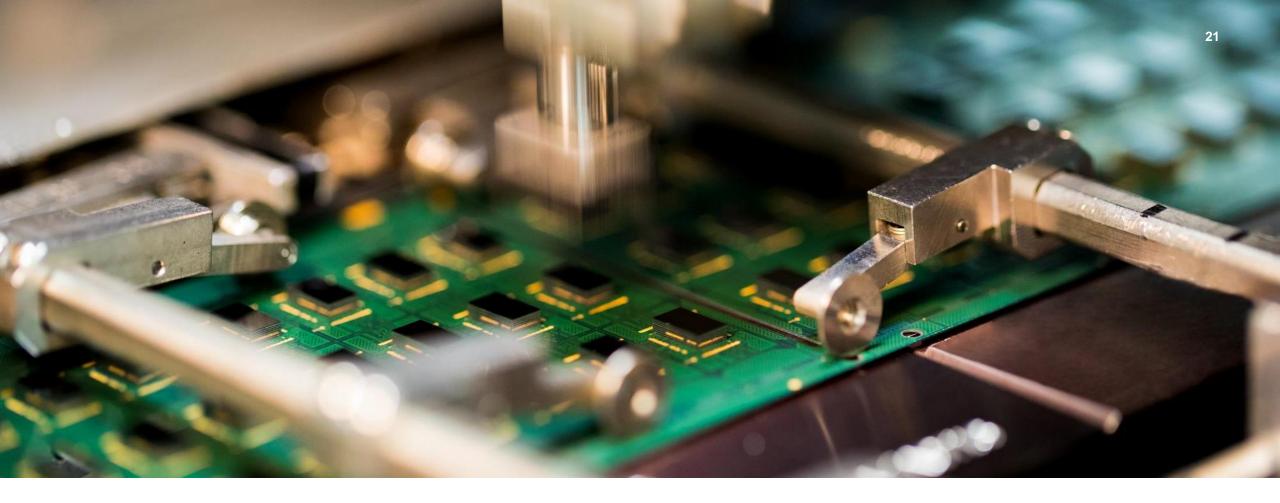
>100 Layers		
Floating Gate	Replacement Gate	

FG made sense for <100 layers

RG is superior for >100 layers







Product



Broadest Portfolio of Memory and Storage Products

Ultra-Bandwidth Solutions

Mobile Leadership

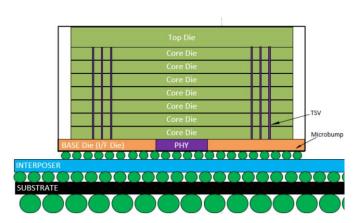
SSD Leadership



Ultra-Bandwidth Solutions for Al Training and Inference from Edge to Cloud

HBM2E: Al Training & Inference for Cloud

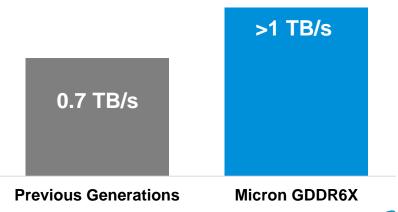
- Enabling system bandwidth >2 TB/s
- Shipping to Customers
- >20 years of experience in stacked TSV memory with thousands of patents



GDDR6X: Al Inference for Edge

By using PAM4 multi-level signaling, Micron GDDR6X transfers more data at a much faster rate, moving two bits of information at a time, doubling the I/O data rate.

System Bandwidth







Memory LPDDR5, LPDDR4x

Storage Solutions

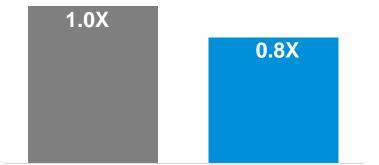
UFS3.1, UFS2.x, eMMC

Multichip Packages (MCPs)

uMCP5, uMCP4x, eMCP4x

Leveraging low power DRAM and NAND technology leadership

LP5 Power Consumption 8k Video Recording (lower = better)



Micron

Competition refers to LP5 products offered by our industry competitors

Competition

Redefining the **End-User Experience**

- Al & machine learning
- Rapid high-resolution photo/video capture
- Longer battery life
- Shorter app launch times
- Multi-tasking capability



Broad SSD Portfolio Spanning cost, performance and end-markets

Datacenter

NVMe, SATA leader, QLC, X100

Client

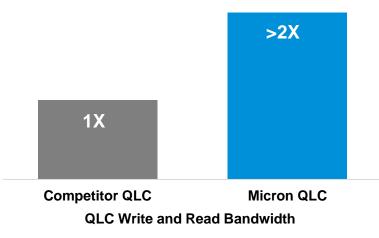
NVMe, SATA, QLC

Auto

Specialized NVMe BGA SSD

Leveraging 176 Layer leadership Using a growing mix of internally developed controllers

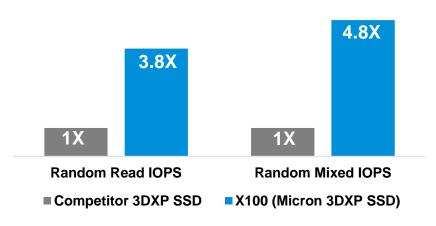
QLC Performance Leadership (higher = better)



QLC leadership accelerating opportunity for HDD replacement

Breakthrough Performance with 3DXP

(higher = better)



X100 – world's fastest SSD pushing the frontier of possibilities



Transforming how the world uses information to enrich life for all.

Industry's leading technology for DRAM and NAND

Industry's broadest portfolio, driving to deliver product leadership Partnering with customers to unleash the value of data for all



